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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/923,647	08/07/2001	Roman J. Hamerski	12263.15	1145	
27526	7590 09/09/2003	•		-90-	
BLACKWELL SANDERS PEPER MARTIN LLP TWO PERSHING SQUARE 2300 MAIN STREET, SUITE 1000			EXAMINER		
			SOWARD, IDA M		
KANSAS CI	TY, MO 64108	,	ART UNIT	PAPER NUMBER	
			2822		
			DATE MAILED: 09/09/2003		

Please find below and/or attached an Office communication concerning this application or proceeding.

				$ \kappa$			
		Application No.	Applicant(s)				
		09/923,647	HAMERSKI ET AL.	HAMERSKI ET AL.			
	Office Action Summary	Examiner	Art Unit				
		Ida M Soward	2822				
Period fo	The MAILING DATE of this communication app or Reply	pears on the cover sheet wi	th the correspondence addr	ess			
THE - External control	ORTENED STATUTORY PERIOD FOR REPL'MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1.1 SIX (6) MONTHS from the mailing date of this communication. a period for reply specified above is less than thirty (30) days, a reply be period for reply is specified above, the maximum statutory period of the period for reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a re y within the statutory minimum of thirt will apply and will expire SIX (6) MON , cause the application to become AB	eply be timely filed y (30) days will be considered timely. THS from the mailing date of this comr ANDONED (35 U.S.C. § 133).	nunication.			
Status							
1)⊠	Responsive to communication(s) filed on						
2a)⊠	,—	is action is non-final.					
3) 🗌 Dispositi	Since this application is in condition for allowated closed in accordance with the practice under tion of Claims			nerits is			
	Claim(s) <u>6-21 and 24</u> is/are pending in the app	olication					
	4a) Of the above claim(s) <u>16-20</u> is/are withdraw						
	Claim(s) is/are allowed.						
	⊠ Claim(s) <u>6-15,21 and 24</u> is/are rejected.						
7)							
8)	Claim(s) are subject to restriction and/or	r election requirement.					
	on Papers	•					
9) 🗌 🤈	The specification is objected to by the Examine	r.					
10) 🗌 .	The drawing(s) filed on is/are: a)□ accep	oted or b) objected to by th	ne Examiner.				
	Applicant may not request that any objection to the	e drawing(s) be held in abeya	nce. See 37 CFR 1.85(a).				
11) 🔲 -	The proposed drawing correction filed on	_is: a)□ approved b)□ di	sapproved by the Examiner.				
	If approved, corrected drawings are required in rep	oly to this Office action.					
12) 🔲 -	The oath or declaration is objected to by the Exa	aminer.					
Priority u	ınder 35 U.S.C. §§ 119 and 120						
13)	Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. §	119(a)-(d) or (f).				
a)[☐ All b)☐ Some * c)☐ None of:						
	1. Certified copies of the priority documents	s have been received.					
	2. Certified copies of the priority documents	s have been received in Ap	pplication No				
* S	3. Copies of the certified copies of the prior application from the International Bursee the attached detailed Office action for a list of the control of the control of the control of the control of the certified copies of the prior applications.	reau (PCT Rule 17.2(a)).		age			
	cknowledgment is made of a claim for domestic	· ·		onlication)			
a	\bigcap The translation of the foreign language pro-	visional application has be	en received.	рпсацопу.			
	Acknowledgment is made of a claim for domesting to the compact of	c priority under 35 U.S.C.	§§ 120 and/or 121.				
Attachment	• •	A) []	(DTO 440) D				
2) 🔲 Notice	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Ir	ummary (PTO-413) Paper No(s). Iformal Patent Application (PTO-1)				

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DETAILED ACTION

This Office Action is in response to the Applicants' amendment filed June 20, 2003.

Double Patenting

The nonstatutory double patenting rejection has been withdrawn due to the amendment filed.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 6-9, 12, 15, 21 and 24 are rejected under 35 U.S.C. 103(a) as being unpatentable over Blackstone et al. (5,164,813).

Blackstone et al. teach an electrical semiconductor device comprising: an epitaxial layer **361** of relatively high resistivity material of one conductivity type and having opposing first and second surfaces, wherein the second surface is etched, and the dopant region **295** is diffused in the second surface of the epitaxial layer **293**; the etched second surface of the epitaxial layer of relatively high resistivity material forms a

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well that reduces an area of the relatively high resistivity material in the second surface of the epitaxial layer of relatively high resistivity material to reduce a resulting electric field; the second surface of the epitaxial layer of relatively high resistivity material receives a lesser amount of diffused material to form a well that reduces an area of the relatively high resistivity material in the second surface of the epitaxial layer of relatively high resistivity material to reduce a resulting electric field; a substrate 360 of relatively low resistivity material of a conductivity type opposite to the one conductivity type and having a surface substantially contiguous to the firs surface of the epitaxial layer; and a dopant region 365 of relatively low resistivity material of the one conductivity type having a surface substantially contiguous to the second surface of the epitaxial layer. In regard to how the layer was grown and how the silicon oxide mask is applied, note that a "product by process" claim is directed to the product per se, no matter how actually made, In re Hirao, 190 USPQ 15 at 17 (footnote 3). See also In re Brown, 173 USPQ 685; In re Luck, 177 USPQ 523; In re Wertheim, 191 USPQ 90 (209 USPQ 554 does not deal with this issue); In re Fitzgerald, 205 USPQ 594, 596 (CCPA); In re Marosi et al., 218 UPSQ 289 (CAFC); and most recently, In re Thorpe et al., 227 UPSQ 964 (CAFC, 1985) all of which make it clear that it is the final product per se which must be determined in a "product by process" claim, and not the patentability of the process, and that, as here, an old or obvious product produced by a new method is not patentable as a product, whether clamed in "product by process" claims or not. Note that Applicant has burden of proof in such cases as the above case law makes clear. Therefore, it would have been obvious to one having ordinary skill in the art at the time the invention

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was made to modify diode structure of the epitaxial layer second surface of Figure 34 by incorporating the epitaxial layer second surface of Figure 24 as taught by Blackstone et al. to obtain a resistance to mechanical, thermal and reverse breakdown stresses.

Claims 10-11 and 13-14 are rejected under 35 U.S.C. 103(a) as being unpatentable over Blackstone et al. (5,164,813) as applied to claim s 6-9, 12, 15 and 24 above, and further in view of Hamerski (US 2002/0163059 A1).

Blackstone et al. and Hamerski teach all mentioned in the rejection above. However, Blackstone et al. and Hamerski fail to teach an epitaxial region including a germanium stress-relieving dopant. Hamerski teaches an epitaxial region including a germanium stress-relieving dopant (page 4, claims 10-11). Since Blackstone et al. and Hamerski are both from the same field of endeavor (high voltage diodes), the purpose disclosed by Hamerski would have been recognized in the pertinent art of Blackstone et al. Therefore, it would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the high voltage diodes of Blackstone et al. by incorporating the germanium stress-relieving dopant of Hamerski to increase operational voltage. Blackstone et al. and Hamerski disclose a central well for each individual device.

Response to Arguments

Applicant's arguments filed 06-20-03 have been fully considered but they are not persuasive. In regard to the remarks on page 6 concerning etching, note that a "product

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by process" claim is directed to the product per se, no matter how actually made. In re-Hirao, 190 USPQ 15 at 17 (footnote 3). See also In re Brown, 173 USPQ 685; In re Luck, 177 USPQ 523; In re Wertheim, 191 USPQ 90 (209 USPQ 554 does not deal with this issue); In re Fitzgerald, 205 USPQ 594, 596 (CCPA); In re Marosi et al., 218 UPSQ 289 (CAFC); and most recently, In re Thorpe et al., 227 UPSQ 964 (CAFC, 1985) all of which make it clear that it is the final product per se which must be determined in a "product by process" claim, and not the patentability of the process, and that, as here, an old or obvious product produced by a new method is not patentable as a product, whether clamed in "product by process" claims or not. Note that Applicant has burden of proof in such cases as the above case law makes clear. Since the Blackstone et al. and Hamerski are from the same field of endeavor (high voltage diodes), the purpose disclosed by Hamerski would have been recognized in the pertinent art of Blackstone et al. Blackstone et al. (Figure 34) and Hamerski (Figures 1 and 4) disclose a central well for each individual device and reduced distance between the layers 360 & 361 of Blackstone et al. and 22 & 24 of Hamerski, but the claims are void of the limitation that a conductive layer can be introduced into the well. In regard to the remarks on page 7 concerning the reduction of the electric field, claims directed to apparatus must be distinguished from the prior art in terms of structure rather than function. In re Danly, 263, F.2d 844, 847, 120 USPQ 528, 531 (CCPA 1959). "Apparatus claims cover what a devices is, not what a device does." Hewlett-Packard Co. v. Bausch & Lomb Inc., 909 F.2d 1464, 1469, 15 USPQ2d 1525, 1528 (Fed. Cir. 1990).

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Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Ida M Soward whose telephone number is 703-305-3308. The examiner can normally be reached on Monday - Thursday, 6:30 am to 5:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Amir Zarabian can be reached on 703-308-4905. The fax phone numbers for the organization where this application or proceeding is assigned are 703-872-9318 for regular communications and 703-872-9319 for After Final communications.

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Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

ims

August 26, 2003

AMIR ZARABIAN
SUPERVISORY PATENT EXAMINER
TECHNOLOGY CENTER 2800